IN THE CLAIMS:

Please cancel claims 17-26 without prejudice, and amend the claims as follows:

1. (Currently Amended) A composition for polishing a metal, the composition comprising:

[[(a)]] a reagent comprising:

[[(i)]] a first moiety for oxidizing the metal; and

[[(ii)]] a second moiety for minimizing overetching the metal; [[and]]

[[(b)]] a stannate salt for stabilizing the composition;

a corrosion inhibitor; and

a base.

2. (Original) The composition according to claim 1, wherein the first moiety is reduced to a complexing agent for the metal or oxidized metal.

3. (Previously Presented) The composition according to claim 2, wherein the first moiety comprises a peroxide group selected from the group of a peroxycarboxylic acid group, a peroxycarboxylate group, and combinations thereof, and the resulting complexing agent comprises a carboxylic acid or a carboxylate.

4. (Original) The composition according to claim 1, wherein the second moiety comprises an alkyl group, an alkyl group derivative, an aryl group, an aryl group derivative, or combinations thereof.

5. (Original) The composition according to claim 4, wherein the second moiety is selected from the group of polyethylene glycol, polyethylene glycol derivatives, benzene, benzene derivatives, and combinations thereof.

6. (Original) The composition according to claim 1, wherein the reagent comprises between about 0.005 wt.% and about 25 wt.% of the composition.

7. (Original) The composition according to claim 1, wherein the stannate salt comprises between about 0.1 ppm and about 20 ppm of the composition.

8. (Original) The composition according to claim 1, wherein the stannate salt is selected from the group of sodium stannate, potassium stannate, ammonium stannate, and combinations thereof.

9. (Currently Amended) The composition according to claim 1[[2]], ~~further comprising a~~ wherein the base is provided in a sufficient amount to increase the solubility of the resulting complexing agent by forming a salt thereof.

10. (Currently Amended) The composition according to claim 9, wherein the base comprises ammonium hydroxide or potassium hydroxide ~~to adjust the pH to about 7~~.

11. (Currently Amended) The composition according to claim 1, ~~further comprising a corrosion inhibitor to adjust~~ wherein the composition has a pH of about 7.

12. (Currently Amended) The composition according to claim [[11]] 1, wherein the corrosion inhibitor is selected from the group of benzotriazole, imidazole, benzimidazole, benzothiazole, mercaptobenzotriazole, 5-methyl-1-benzotriazole, and combinations thereof.

13. (Currently Amended) The composition according to claim [[11]] 1, wherein the corrosion inhibitor comprises between about 0.005 wt.% and about 0.05 wt.% of the composition.

14. (Original) The composition according to claim 1, further comprising abrasive particles at a concentration between about 0.1 wt.% and about 30 wt.% of the composition.

15. (Original) The composition according to claim 3, wherein the peroxycarboxylic acid group is selected from the group of peroxyacetic acid, peroxybenzoic acid, chlorobenzoic acid, peroxyformic acid, polyethylene glycol peroxy acid, and combinations thereof.

16. (Original) The composition according to claim 1, wherein the reagent comprises an amine-peroxy acid.

17-26. (Cancelled)

27. (Currently Amended) A composition for polishing a metal, the composition comprising:

[[(a)]] a reagent comprising:

[[(i)]] a first moiety comprising a peroxide group selected from the group of a peroxycarboxylic acid group, a peroxycarboxylate group, and combinations thereof; and

[[(ii)]] a second moiety comprising an alkyl group, an alkyl group derivative, an aryl group, an aryl group derivative, or combinations thereof; [[and]]

[[(b)]] a stannate salt;

a corrosion inhibitor; and

a base.

28. (Original) The composition according to claim 27, wherein the peroxide group reduces to form a complexing agent comprising a carboxylic acid, a carboxylate, or combinations thereof.

29. (Original) The composition according to claim 27, wherein the reagent comprises between about 0.005 wt.% and about 25 wt.% of the composition.

30. (Original) The composition according to claim 27, wherein the stannate salt comprises between about 0.1 ppm and about 20 ppm of the composition, and wherein

the stannate salt is selected from the group of sodium stannate, potassium stannate, ammonium stannate, and combinations thereof.

31. (Currently Amended) The composition according to claim 27, further comprising ~~a base, a corrosion inhibitor,~~ abrasive particles~~, or combinations thereof~~.

32. (Original) The composition according to claim 27, wherein the reagent comprises an amine-peroxy acid.

Please add new claims 33-42 as follows:

33. (New) A composition for polishing a metal, the composition comprising:
a reagent comprising:
a first moiety for oxidizing the metal; and
a second moiety for minimizing overetching the metal;
a stannate salt for stabilizing the composition; and
a base to adjust the pH to about 7.

34. (New) The composition according to claim 33, wherein the base is provided in a sufficient amount to increase the solubility of the resulting complexing agent by forming a salt thereof.

35. (New) The composition according to claim 33, wherein the base comprises ammonium hydroxide or potassium hydroxide.

36. (New) The composition according to claim 33, wherein the first moiety comprises a peroxide group selected from the group of a peroxycarboxylic acid group, a peroxycarboxylate group, and combinations thereof, and the resulting complexing agent comprises a carboxylic acid or a carboxylate.

37. (New) The composition according to claim 33, wherein wherein the peroxycarboxylic acid group is selected from the group of peroxyacetic acid, peroxybenzoic acid, chlorobenzoic acid, peroxyformic acid, polyethylene glycol peroxy acid, and combinations thereof, and the second moiety comprises an alkyl group, an alkyl group derivative, an aryl group, an aryl group derivative, or combinations thereof.

38. (New) The composition according to claim 33, wherein the reagent comprises between about 0.005 wt.% and about 25 wt.% of the composition and the stannate salt comprises between about 0.1 ppm and about 20 ppm of the composition.

39. (New) The composition according to claim 33, wherein the stannate salt is selected from the group of sodium stannate, potassium stannate, ammonium stannate, and combinations thereof.

40. (New) The composition according to claim 33, wherein the corrosion inhibitor is selected from the group of benzotriazole, imidazole, benzimidazole, benzothiazole, mercaptobenzotriazole, 5-methyl-1-benzotriazole, and combinations thereof.

41. (New) The composition according to claim 33, wherein the corrosion inhibitor comprises between about 0.005 wt.% and about 0.05 wt.% of the composition.

42. (New) The composition according to claim 33, further comprising abrasive particles at a concentration between about 0.1 wt.% and about 30 wt.% of the composition.